Electron–phonon coupling is large for localized states

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From density-functional calculations, we show that localized states stemming from defects or topological disorder exhibit an anomalously large electron–phonon coupling. We provide a simple analysis to explain the observation and perform a detailed study on an interesting system: amorphous silicon. We compute first-principles deformation potentials (by computing the sensitivity of specific electronic eigenstates to individual classical normal modes of vibration). We also probe thermal fluctuations in electronic eigenvalues by first-principles thermal simulation. We find a strong correlation between a static property of the network (localization, as gauged by inverse participation ratio (IPR)) and a dynamical property (the amplitude of thermal fluctuations of electron energy eigenvalues) for localized electron states. In particular, both the squared electron–phonon coupling and the variance of energy eigenvalues are proportional to the IPR of the localized state. We compare the results for amorphous Si to photoemission experiments. While the computations are carried out for silicon, very similar effects have been seen in other systems with disorder.

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I. INTRODUCTION

Electron states of finite spatial extent, so called “localized” states are ubiquitous in nature. Localized molecular orbitals occur in molecules and in solid state systems with disorder (this could take the form of defects, such as a dangling bond state, or more subtly from topological and or chemical disorder in amorphous materials or glasses). Such localized states are also known in polymers. Surface states, as another form of defect, also are often spatially compact. The study of localization in its own right has been an important and active subfield of condensed matter theory since the fifties.

A physical quantity of key importance is the electron–phonon (e–p) coupling, the interaction term connecting the electronic and lattice systems. Perhaps most spectacularly, the e–p coupling is the origin of superconductivity as expressed in BCS theory. Phillips has shown that large e–p couplings in the cuprate superconductors can lead to a successful model of high Tc superconductivity within the framework of conventional BCS superconductivity. The e–p coupling is also the mediator of all light-induced structural changes in materials. In amorphous silicon the greatest outstanding problem of the material, the Staebler-Wronski effect, depends critically upon the electron-lattice interaction. Many analogous effects are studied in glasses; perhaps the most important example is reversible photoamorphization and photocrystallization used in the GeSbTe phase-change materials used in current writable CD and DVD technology.

Previous thermal simulations with Bohn-Oppenheimer dynamics have indicated that there exists a large electron–phonon coupling for the localized states in the band tails and in the optical gap. Earlier works on chalcogenide glasses by Cobb and Drabold have emphasized a strong correlation between the thermal fluctuations as gauged by root mean square (r.m.s.) variation in the LDA eigenvalues and wave function localization of a gap or tail state (measured by inverse participation ratio, a simple measure of localization). Drabold and Fedders have also shown that localized eigenvectors may fluctuate dramatically even at room temperature. Recently, Li and Drabold relaxed the adiabatic (Born-Oppenheimer) approximation to track the time-development of electron packets scattered by lattice vibrations. In this paper, we examine the electron phonon coupling and provide a heuristic analysis of the e–p coupling for localized electron states. We explore the e–p coupling in some detail for a particular model system (amorphous silicon) which provides us with a convenient variety of localized, partly localized “band tail” and extended states. We compute deformation potential (which measures the response of a selected electron state to a particular phonon), and also track thermally induced fluctuations of electronic eigenvalues. We find that localized states always exhibit a large e–p coupling. Our computations are carried out using a first principles molecular dynamics code SIESTA, and the eigenvalues and states that we study are from the Kohn-Sham equations with a rich local orbital basis. A rationale for the study of the Kohn-Sham states is given elsewhere. We emphasize that the results that we give are qualitatively general—not just an artifact of studying a disordered phase of silicon (we have, for example, seen exactly the same effects in various binary glasses which exhibit very different topological and chemical disorder).

II. THEORY

To establish a connection between electron-phonon coupling and wave function localization for the electrons, we consider an electronic eigenvalue λn near the band gap of a-Si. The sensitivity of λn due to an arbitrary small displacement of an atom (possibly thermally induced) can be estimated using the Hellmann-Feynman theorem

$$\frac{\partial \lambda_n}{\partial R_a} = \langle \psi_n | \frac{\partial H}{\partial R_a} | \psi_n \rangle.$$

Here we have assumed that the basis functions are fixed and |ψn⟩ are the eigenvectors of the Hamiltonian H. For small
lattice distortion \( \{ \mathbf{R}_i \} \), the corresponding change in \( \delta n \) is

\[
\delta n_n = \sum_{\alpha=1}^{3N} \left\langle \psi_n \right| \frac{\partial H}{\partial \mathbf{R}_\alpha} \left| \psi_n \right\rangle \delta \mathbf{R}_\alpha, \tag{1}
\]

where \( N \) is the total number of atoms in the model. If the displacement \( \delta \mathbf{R}_\alpha(t) \) arises from classical vibrations, one can write\(^1^2\)

\[
\delta \mathbf{R}_\alpha(t) = \sum_{\omega \neq 0}^{3N} A(T, \omega) \cos(\omega t + \phi_\omega) \chi_\alpha(\omega), \tag{2}
\]

where \( \omega \) indexes the normal mode frequencies, \( A(T, \omega) \) is the temperature-dependent amplitude of the mode with frequency \( \omega \), \( \phi_\omega \) is an arbitrary phase, \( \chi_\alpha(\omega) \) is a normal mode with frequency \( \omega \) and vibrational displacement index \( \alpha \). Using the temperature dependent squared amplitude \( A^2 = k_B T/M \omega^2 \), the trajectory (long time) average of \( \delta n_n \) can be written [using Eqs. (1) and (2)] as

\[
\langle \delta n_n \rangle = \lim_{\tau \to \infty} \frac{1}{\tau} \int_0^\tau dt \delta n_n^2(t) = \left( \frac{k_BT}{2M} \right) \sum_{\alpha=1}^{3N} \Xi_\alpha^2(\omega) \omega^2, \tag{3}
\]

where the electron-phonon coupling \( \Xi_\alpha(\omega) \) is given by

\[
\Xi_\alpha(\omega) = \sum_{\alpha=1}^{3N} \left\langle \psi_n \right| \frac{\partial H}{\partial \mathbf{R}_\alpha} \left| \psi_n \right\rangle \chi_\alpha(\omega). \tag{4}
\]

One can infer from Eq. (3) that thermally induced fluctuation in the energy eigenvalues is a consequence of electron-phonon coupling. Note that for a given electronic eigenvalue, the contribution to the coupling comes from the entire vibrational spectrum involving all the atoms in the systems. Since the normalized eigenstate can be written as \( |\psi_n\rangle = \sum_i a_{n i} |i\rangle \) where \( |i\rangle \) are the basis orbitals, it follows from Eq. (4) that

\[
\Xi_\alpha^2(\omega) = \sum_{\alpha, \beta, \mu, \nu} a^*_n a_{n \mu} a^*_n a_{n \nu} \left\langle i | \frac{\partial H}{\partial \mathbf{R}_\alpha} | j \right\rangle \left\langle j | \frac{\partial H}{\partial \mathbf{R}_\beta} | l \right\rangle \chi_\alpha(\omega) \chi_\beta(\omega)
\]

\[
= \sum_{i, \alpha} |a_{n i}|^4 \left( \left| \left\langle i | \frac{\partial H}{\partial \mathbf{R}_\alpha} | j \right\rangle \right|^2 \chi_\alpha^2(\omega) \right.
\]

\[
+ \sum_{ijkl, \alpha} a^*_n a_{n \mu} a^*_n a_{n \nu} \left( \left| \left\langle i | \frac{\partial H}{\partial \mathbf{R}_\alpha} | j \right\rangle \right|^2 \chi_\alpha(\omega) \chi_\beta(\omega) \right).
\]

The first term in the second line of Eq. (5) is positive definite (diagonal) while the second one, the off-diagonal term (indicated by the prime), is not of a single sign. In the event that only a few \( a_{n i} \) dominate (the case for localized states), then the leading contribution to the electron-phonon coupling originates largely from the diagonal term. The addition of a large number of terms of mixed sign and small magnitude leads to cancellations in the off-diagonal term leaving behind a small contribution to electron-phonon coupling. By comparing to direct calculations with the full Eq. (5), we show that dropping the second term appears to be reasonable for well-localized electron states. The approximate “diagonal” electron-phonon coupling can be written as

\[
\Xi_\alpha^2(\omega) = \sum_{\alpha=1}^{3N} \sum_{i=1}^{N_b} |a_{n i}|^2 \left| \left\langle i | \frac{\partial H}{\partial \mathbf{R}_\alpha} | j \right\rangle \right|^2 \chi_\alpha^2(\omega)
\]

\[
= \sum_{\alpha=1}^{3N} \sum_{i=1}^{N_b} q_{n i}^2 \left| \left\langle i | \frac{\partial H}{\partial \mathbf{R}_\alpha} | j \right\rangle \right|^2 \chi_\alpha^2(\omega), \tag{6}
\]

where \( N_b \) is the number of basis orbitals and \( q_{n i} = |a_{n i}|^2 \) is the charge sitting on the \( i \)th orbital for a given normalized eigensate \( |\psi_n\rangle \). The degree of wave function localization can be measured by defining inverse participation ratio \( I \) for the eigensates \( |\psi_n\rangle \)

\[
I(n) = \sum_{i=1}^{N_b} q_{n i}^2. \tag{7}
\]

Equation (6) leads to an approximate but analytic connection between \( I \) and electron-phonon coupling. Since \( I \) is large for localized states, one expects \( \Xi_\alpha^2(\omega) \) to be large for a localized state. If we further assume that \( \gamma^2(\omega, i) = \sum_{\alpha=1}^{3N} \left| \left\langle i | \frac{\partial H}{\partial \mathbf{R}_\alpha} | j \right\rangle \right|^2 \chi_\alpha^2(\omega) \) is weakly dependent upon site/orbital index \( i \), then

\[
\Xi_\alpha^2(\omega) \sim I(n) \times f(\omega), \tag{8}
\]

where \( f(\omega) \) is defined from \( \gamma^2 \) and Eq. (6). In this “separable” approximation, it is also the case that \( \langle \delta n_n^2 \rangle \sim I(n) \).

### III. METHOD

The model of \( a \)-Si we have used in our calculations was generated by Barkema and Mousseau\(^1^3\) using an improved version of the Wooten, Winer, and Weaire (WWW) algorithm.\(^1^4\) The details of the construction was reported in Ref. 13. The model consists of 216 atoms of Si packed inside a cubic box of length 16.282 Å and has two threefold coordinated atoms. The average bond angle is 109.5° with a root mean square deviation of 11.0°. The density functional calculations were performed within the local density approximation (LDA) using the first principles code SIESTA.\(^1^3^-^1^5\) We have used a non-self-consistent version of density functional theory based on the linearization of the Kohn-Sham equation by Harris functional approximation\(^1^8\) along with the parametrization of Perdew and Zunger\(^1^9\) for the exchange-correlation functional.\(^2^0\) The choice of an appropriate basis is found be very important and has been discussed at length in a recent communication.\(^1^0\) While the minimal basis consisting of one \( s \) and three \( p \) electrons can adequately describe the electronic structure of amorphous silicon in general, there is some concern about the applicability of these minimal basis in describing deeply localized and low-lying excited states in the conduction bands accurately. We have therefore employed a larger single-\( \xi \) basis with polarization \( (d) \) orbitals (SZP)\(^2^1^-^2^2\) in the present work. Throughout the calculation we have used only the \( \Gamma \) point to sample the Brillouin zone.

Starting with a fully relaxed configuration, we construct the dynamical matrix elements by successively displacing each atom in the supercell along three orthogonal directions \( (x, y, \text{ and } z) \) by 0.01 Å and computing the forces for each configuration. Within the harmonic approximation, the
spring constant associated with each atom and direction can be written as a second derivative of the total energy with respect to the displacement of the atom in that direction. We have checked the convergence of both the matrix elements by using a different set of values for atomic displacement and used a value of 0.01 Å in our calculations. ∂h/∂R was obtained by finite differences from the dynamical matrix calculations. The calculation does not need any extra effort beyond that of forming the dynamical matrix. We note that the vibrational density of states is well reproduced compared to experiments.\(^{23}\)

To explore the validity of our analysis and to elucidate the connection between the localization (IPR) (I) of electronic eigenstates and fluctuation of the conjugate eigenvalues, we performed thermal MD simulations at constant temperatures using a Nose-Hoover thermostat. The simulations were performed at temperatures 150, 300, 500, and 700 K with a time step of 2.5 fs for a total period of 2.5 ps. For a given temperature, the mean square fluctuations were computed by tracking the eigenvalues at each time step and averaging over the total time of simulation excepting the first few hundred time steps to ensure equilibration.

The mean square fluctuation (R) for an energy eigenvalue \(\lambda_n(t)\) is defined as
\[
R_n = \langle (\lambda_n(t) - \langle \lambda_n \rangle)^2 \rangle,
\]
where \(\langle \cdots \rangle\) denotes the average over time. We study the fluctuations of \(\lambda_n(t)\) by plotting against time at a given temperature and compare it with the I obtained for the corresponding eigenvalues. For illustrations of such adiabatic evolution of Kohn-Sham eigenvalues, see Ref. 9.

**IV. RESULTS**

In Fig. 1, we have plotted the electron–phonon coupling for the states near the band gap obtained directly from Eq. (4). It is clear from the figure that the e-p coupling is large only in the vicinity of conduction and valence band tails. The largest e-p coupling in the plot corresponds to the highest occupied molecular orbital (HOMO) in the optical frequency regime around 415 cm\(^{-1}\). The lowest occupied molecular orbital (LUMO) also has a large feature around the same frequency. A Mulliken charge analysis and inverse participation ratio calculation of the electronic eigenfunctions have shown that both these states—the HOMO and LUMO—are highly localized and are centered around the dangling bonds present in the model. On moving further from the band tails in either direction along the energy axis, the e-p coupling drops quickly and the surface becomes featureless for a given eigenvalue. This behavior of e-p coupling can be understood from the arguments presented in Sec. II where we have shown that the e-p coupling for localized states is directly proportional to the inverse participation ratio. For a localized state, therefore, the large value of electron–phonon coupling can be attributed to the large value of inverse participation ratio associated with that state. Since HOMO and LUMO are the two most localized states in the spectrum, the e-p coupling is large for these states and as we move toward the tail states, the coupling decreases. It is important to note that the plot in the Fig. 1 has been obtained from Eq. (4) without making any approximation and is exact inasmuch as the matrix elements obtained from the density functional Hamiltonian are correct. This observation supports our assumptions that the dominant contribution to e-p coupling comes from the diagonal term in Eq. (5) and that \(\gamma^2(\omega, i)\) is weakly dependent upon site/orbital index \(i\) and also indicates from direct simulation there exists a linear relationship between mean square fluctuation of electronic eigenvalues and the corresponding inverse participation ratio for localized states. We performed analogous calculations on crystalline Si and found no anomalous e-p couplings, as our analysis of Sec. II would suggest.

In order to justify our arguments further presented in Sec. II, we now give a look at the mean square fluctuation of energy eigenvalues. As outlined in Sec. III, we have computed the mean square fluctuations at four different temperature (150, 300, 500, and 700 K) from MD runs over a period of 2.5 ps and plotted in Fig. 2. The fluctuation obtained this way provides a dynamical characteristic of the band tails states and is compared with a static property, the inverse participation ratio of the same states. A simple linear fit reveals a strong correlation between the eigenvalue fluctuation and the corresponding inverse participation ratio for the states. The correlation is found to be as high as \(\approx 0.95\) for \(T=150\) and 300 K and falls to \(\approx 0.8\) at high temperature. The value of the correlation coefficient for different temperature is indicated in the Fig. 2. Once again, we see that the result is in accordance with our prediction in Sec. II and provides a simple physical picture for having a large electron–phonon coupling for the localized states.

In Fig. 3, we have plotted the time averaged electronic density of states for four different temperature in order to study the effect of thermal disorder on the tail states. It is quite clear from the figure that the effect of thermal broadening is quite significant on both sides of the gap. Photoelec-
tron spectroscopic studies on a-Si:H by Aljishi et al. have shown that the conduction tail is indeed more susceptible to thermal disorder than the valence tail. The temperature dependence can be conveniently expressed by introducing a characteristic energy $E_0$ and fitting the electronic density of states to $r_s E_d < \exp |E_f/E_0|$. Aljishi et al. expressed the temperature dependence of the tail states by the slope of the $E_0$ vs $T$ plot and obtained a smaller value for the conduction band tail. We have observed a qualitative agreement of our results with experiment. The key observation that one should note from Fig. 3 is the following: the shape of the tail in the conduction band rapidly changes as the temperature rises from 150 to 700 K. The corresponding change in the valence tail for the same range of energy $0.4$ eV is, however, much less and is rather smooth compared to the conduction tail. Since the localized defect states (coming from the two dangling bonds) have been removed before plotting, this observation qualitatively suggests that the conduction tail states are more susceptible to lattice motion. It is tempting to attempt to estimate decay parameters for a direct comparison to experiment, but the sparse sampling of tail states for this 216 atom model makes this a dangerous exercise. The basic features do appear to be represented in our study, however.

V. CONCLUSION

Using accurate methods and a reasonable model of a-Si, we showed that there is (1) a large $e-p$ coupling for localized states and (2) a significant correlation between thermal fluctuation of electron energy eigenvalues conjugate to localized states and the IPR of the model at $T=0$. We find qualitative agreement with photoemission experiments. We provide a simple analytic argument for the origin of these effects. Identical experience with models of other amorphous materials has convinced us that the results are correct in at least a qualitative way for binary glasses and amorphous materials, and perhaps other systems.

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2 J. C. Phillips, Phys. Rev. Lett. 72, 3863 (1994); 59, 1856 (1987); cond-mat/0402111 (unpublished); For an alternative view, see P. W. Anderson, P. A. Lee, T. M. Rice, M. Randeria, N. Trivedi,


5 D. A. Drabold and Jun Li (unpublished).


8 The IPR (I) is in fact a useful but ad hoc measure of localization (a more fundamental gauge is the information entropy). From a practical point of view however, the IPR usually gives a result qualitatively similar to the entropy. See D. A. Drabold, P. Biswas, T. DeNyago, and R. Atta-Fynn, in Non-crystalline Materials for Optoelectronics, edited by M. Popescu and G. Lucovsky (INOE, Bucharest, 2004); cond-mat/0312607 (unpublished).


12 Here we have only considered the Γ point in our calculations which corresponds to $k=W=0$.


20 We verified for one run 300 K that solution of the self-consistent field Kohn-Sham equations was nearly identical with Harris for eigenvalue fluctuations. This is not surprising for this purely covalent system.


